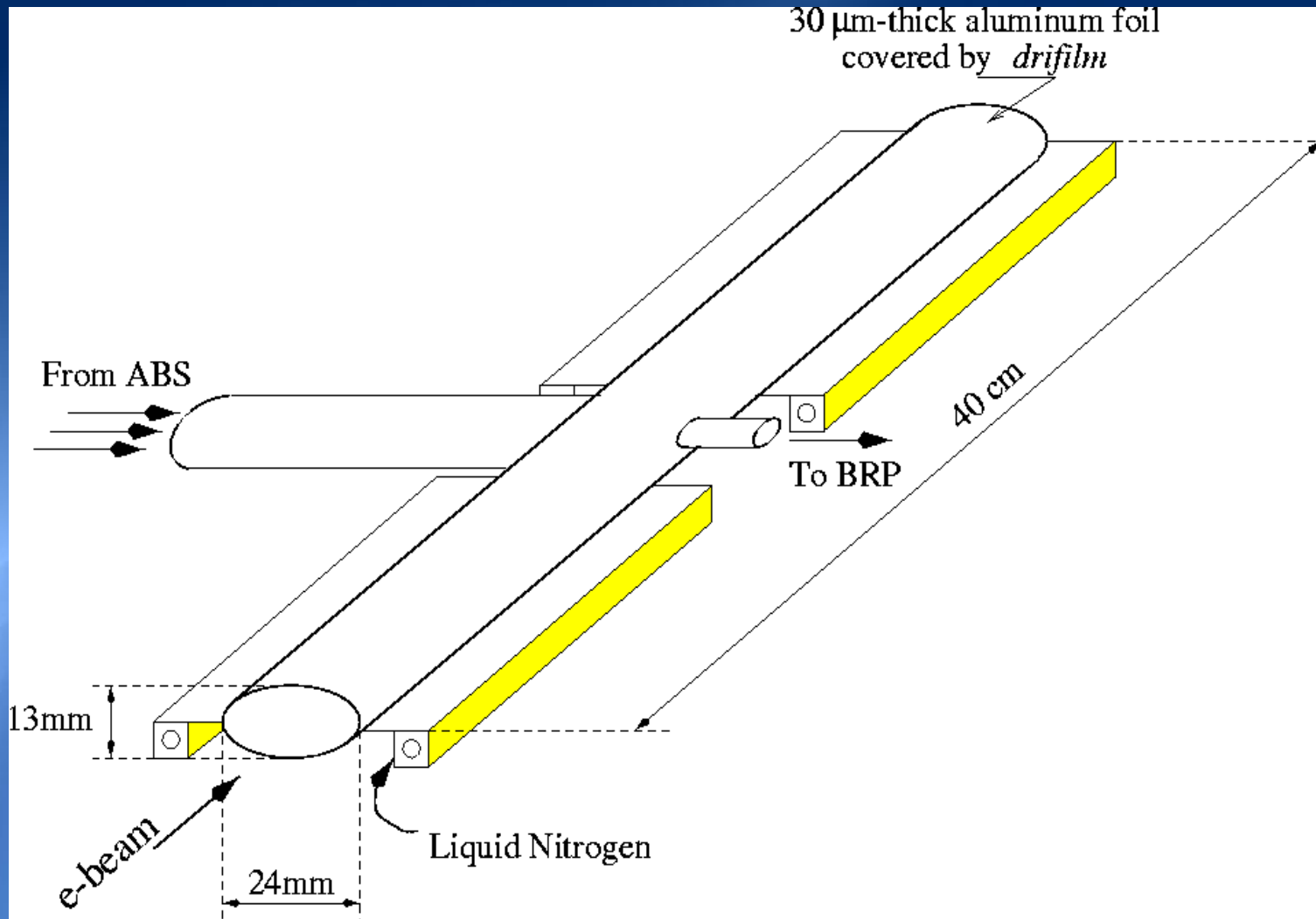


*Efficiency of the injection of the atomic
beam into the storage cell*

Questions to be discussed

- 1. How effectively atomic beam could be injected into the cell when the pressure in the cell is increased**
- 2. Is there fast saturation of the target thickness when the intensity of the beam from ABS is increased?**
- 3. Intrabeam scattering – how to measure this effect?**

Geometry of the cell



Attenuation of the injected beam

$$2 * C * P = I_0 * \exp \{ -\sigma * P * L / 2kT \} + Q_{\text{ext}}$$

R	=	Δ	+	∩	
I0	Qext	P (mbar)	A	B	A+Q
6,91097E+16	0	3,37E-04	4,99E+16	4,89E+16	4,99E+16
6,91097E+16	1,00E+16	3,95E-04	4,72E+16	5,74E+16	5,72E+16
6,91097E+16	2,00E+16	4,47E-04	4,49E+16	6,49E+16	6,49E+16
6,91097E+16	4,00E+16	5,50E-04	4,06E+16	7,99E+16	8,06E+16
6,91097E+16	6,00E+16	6,70E-04	3,62E+16	9,73E+16	9,62E+16
6,91097E+16	8,00E+16	8,00E-04	3,19E+16	1,16E+17	1,12E+17
6,91097E+16	1,00E+17	9,00E-04	2,90E+16	1,31E+17	1,29E+17
6,91097E+16	1,00E+18	7,00E-03	7,99E+13	1,02E+18	1,00E+18

σ

Ext. flux

Decreasing of the intensity of the injected beam due to scattering in the injecting tube (external source into the cell)

σ

Pressure reading in the compression volume vs the external flux

TARGET THICKNESS VS BEAM INTENSITY

$$I_{inj} = I_0 * \exp(-n_0 * \sigma * L/2)$$

$$n_0 = I_{inj} / C_{cell} = I_0 * \exp(-n_0 * \sigma * L/2) / (3 * 6.5 * 10^4 * d^3 / L)$$

$$d = 1 \text{ cm, target thick. } t = n_0 * L, \sigma = 0.8 * 10^{-14} \text{ cm}^2, I_0 = 6.9 * 10^{16}$$

$$x = t * \sigma / 2 \quad 7 * 10^2 * (d/L)^2 * x = \exp(-x)$$

$$\text{Let } (d/L) = 1/20 \text{ than } 1.75 * x = \exp(-x) \quad x = 0.39$$

$$\text{for } 1 * I_0 = 6.9 * 10^{16} \text{ at/sec} \quad t = 9.6 * 10^{13} \text{ at/cm}^2$$

2

15.1

4

22.4

6

27.6

10

34.5

20

45.0

Atomic depolarization due to the wall collisions

$$t_t = (L/d)^2 \cdot t_b$$

$$P_t \propto e^{-\alpha(L/d)^2}$$

$$F = t_t P^2$$

$$L/d = \sqrt{1/2\alpha}$$

$$\alpha \quad 0.001 \quad L/d \quad 20$$